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A Kinetic Study of the Silyl Substitution in Tantalum Amide Silyl Complex (Me2N)3Ta[Si(SiMe3)3]2

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Kinetic studies have been performed for the substitution of the first silyl ligand in (Me₂N)₃Ta[Si(SiMe₃)₃]₂ (1) by Li(THF)₃SiBu'Ph₂ at 233 K (THF = tetrahydrofuran). In the presence of excess Li(THF)₃SiBu'Ph₂, these studies
royael that the reaction likely follows a dissociative pathway. THE a polar selvent is found to premate t reveal that the reaction likely follows a dissociative pathway. THF, a polar solvent, is found to promote the substitution, and the order of the reaction with respect to THF is 1.7(0.3).

Substitution is a fundamental reaction of organometallic complexes,¹ and it has played an important role in the formation of metal complexes.²⁻⁶ The substitution of ligands by silyl anions SiR_3 ⁻ is a common synthetic pathway to yield metal silyl complexes. There have been relatively few studies of kinetics and mechanism in the substitution reactions involving silyl ligands. 2^{-6} We recently found that the silyl ligand in tetracoordinated $(Me_2N)_3Zr-Si(SiMe_3)_3$ undergoes a reversible exchange with SiBu^ph₂⁻, probably through a pentacoordinated, bis(silyl) intermediate {[(Me₂N)₃Zr(SiBu^{*r*Ph₂)-}

 $[(SiMe₃)₃]$ ⁻, to reach the equilibrium in eq 1.⁶ In an analogous exchange involving (Me₂N)₃Zr(SiBu'Ph₂) and SiBu'Ph₂⁻ (eq 2), an unusual bis(silyl) intermediate $trans-(Me₂N)₃Zr-$ (SiBu*^t* Ph2)2 - was isolated and structurally characterized.

> $(Me_2N)_3Zr-Si(SiMe_3)_3 + SiBu^tPh_2^{\Theta} =$ (1) $(\text{Me}_2\text{N})_3\text{Zr-SiBu}^{\dagger}$ Ph₂ + Si(SiMe₃)₃⁰ $\Delta H^{\circ} = -4.6(0.5)$ kcal/mol and $\Delta S^{\circ} = -7(2)$ eu

In comparison, the substitution of the silyl ligands in pentacoordinated (Me₂N)₃Ta[Si(SiMe₃)₃]₂ (1) by SiBu^{*I*ph₂⁻} at 23 $\rm{^{\circ}C}$ (Scheme 1) was found to be irreversible.^{6b} The two $-Si(SiMe₃)$ ₃ ligands in **1** are replaced sequentially by SiBu^{*Ph*₂⁻ to give (Me₂N)₃Ta(SiBu^{*Ph*₂)[Si(SiMe₃)₃] (2) and}} then $(Me_2N)_3Ta(SiBu'Ph_2)_2$ (3) (eqs 3–4).^{6b,7} Complex 3 is,
however jnert to the exchange with $Si(SiMe_2)_2$ however, inert to the exchange with $Si(SiMe₃)₃$.

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 ΔG^2 _{293 K} = 14.1(0.5) kcal/mol

We were interested in whether the substitution of a silyl ligand in the pentacoordinated 1 by SiBu'Ph₂⁻ followed the dissociative or associative mechanism. The two, consecutive reactions in eqs 3-4 were both silyl substitutions involving an amide silyl complex **1** or **2**. They were expected to follow similar mechanistic pathways, and we thus decided to investigate the first substitution in eq 3. This reaction was found to follow the dissociative mechanism. Tetrahydrofuran (THF) in mixed THF-toluene- d_8 solvents promoted the substitution. Our studies are reported here.

Experimental Section

All manipulations were performed under a dry nitrogen atmosphere. THF was purified by distillation from K/benzophenone ketyl. Toluene- d_8 was dried over molecular sieves. (Me₂N)₃TaCl₂,⁸ Li(THF)₃SiBu^{*I*Ph₂,^{9a} and Li(THF)₃Si(SiMe₃)₃^{9b} were prepared ac-} cording to the literature procedures. 1H NMR spectra were recorded on a Bruker AMX-400 spectrometer and referenced to toluene- d_8 . The NMR spectrometer was precooled to 233(1) K. Values of *k*obs were obtained from at least two separate experiments for a concentration of THF, and their averages are listed. The order *n* and its uncertainty were calculated from an unweighted nonlinear least-squares procedure and the error propagation formulas in eq 5, respectively.10

$$
(\sigma n)^2 = \frac{2(\Delta \ln k)^2}{(\Delta \ln C_{\text{THF}})^4} \left(\frac{\sigma C_{\text{THF}}}{C_{\text{THF}}}\right)^2 + \frac{2}{(\Delta \ln C_{\text{THF}})^2} \left(\frac{\sigma k}{k}\right)^2
$$

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$$
\Delta \ln C_{\text{THF}} = (\ln C_{\text{THF}_{\text{max}}} - \ln C_{\text{THF}_{\text{min}}}) \tag{5}
$$

1 was prepared in situ at 23 °C in a Young NMR tube from $(Me₂N)₃TaCl₂ (5.0 mg, 0.013 mmol)$ and Li(THF)₃Si(SiMe₃)₃ (16.4) mg, 0.0349 mmol) in toluene- d_8 , using 4,4'-dimethylbiphenyl (4.0) mg) as an internal standard (volume $= 1.07$ mL). A small piece of filter paper was placed on the top of the NMR tube in a glovebox. Li(THF)3SiBu*^t* Ph2 (50.0, 60.0, 80.0, 100.0, or 120.0 mg; 0.108, 0.130, 0.173, 0.216, or 0.260 mmol) was then put on the paper and separated from the solution prior to the cooling of the solution. After the solution was cooled at 203 K for 10 min, the NMR tube was flipped over to mix the solution and Li(THF)₃SiBu^tPh₂ and then immediately inserted into the NMR spectrometer. Values of $C_1/C_{1(0)}$ and C_{THF} (0.61-0.74 M) were measured through the integration of their ¹H NMR resonances ($-NMe₂$ at 3.20 ppm for **1** and $-CH_2$ - at 1.34-1.35 ppm for THF). Values of k_{obs} were derived from the fitting of the data by first-order kinetics (rate $=$ $k_{obs}C_1$; $k_{obs} = k_{obs}/C_{\text{THF}}^{1.7}$ and are given in Table 1. Similar studies were performed with different C_{THF} . C_{THF} and the rate constants $(k_{obs} = k_1 C_{\text{THF}}^n)$ are listed in Table 2.

Results and Discussion

Kinetic Studies of the First Silyl Substitution in 1. Unlike 1, the intermediate (Me₂N)₃Ta(SiBu^{*r*}Ph₂)[Si(SiMe₃)₃] (2) is thermally unstable^{6b} and has not been isolated. In addition, the change in the concentration of **2** during the reaction between 1 and Li(THF)₃SiBu^{*r*}Ph₂ at 233 K was below the detection limit in ¹H NMR spectra.¹¹ In addition, the two steps in the consecutive substitutions in eqs 3 and 4 are similar. The current work thus focused on the first substitution $(1 \rightarrow 2, \text{ eq } 3)$, and studies of the second substitution ($2 \rightarrow 3$, eq 4) were not conducted.

Two possible reaction pathways in Scheme 1 have been considered for eq 3. The first pathway (Path I), a dissociative process, involves $Si(SiMe₃)₃$ ⁻ dissociation from 1 to give a tetracoordinated intermediate (**A**), followed by the addition of SiBu^{*r*Ph₂⁻. The second pathway (Path II), an associative} process, involves the addition of SiBu'Ph₂⁻ to 1 to give a hexacoordinated intermediate (B) , followed by $Si(SiMe₃)₃$ ⁻ dissociation. Each substitution in eqs 3-4 consumes 1 equiv of Li(THF)₃SiBu^{*(Ph*2}. To minimize the effect of eq 4 on eq 3, excess Li(THF)3SiBu*^t* Ph2 (8- to 20-fold) was used.

If the *dissociative* mechanism in Path I (Scheme 1) is operative, the kinetic law for the $1 \rightarrow 2$ conversion through the steady-state approximation is given in eq $6.^{1g}$

$$
-\frac{dC_1}{dt} = \frac{k_1 k_2 C_{\text{LiSi(BuPh}_2} C_{\text{THF}}^n}{k_{-1} C_{\text{LiSi(SiMe}_3)_3} + k_2 C_{\text{LiSiBuPh}_2}} C_1 = k_{\text{obs}} C_1 \tag{6a}
$$

$$
k_{\text{obs}} = \frac{k_1 k_2 C_{\text{LiSiBuPh}_2} C_{\text{THF}}^n}{k_{-1} C_{\text{LiSi(SiMe}_3)_3} + k_2 C_{\text{LiSiBuPh}_2}}
$$
(6b)

The effect of C_{THF} will be discussed below. Let $k_{\text{obs}}' = k_{\text{obs}}/k$

(12) $C_{\text{Lisi}(SiMe_2)}(av) = (0.0089 \text{ mmol} + 0.0349 \text{ mmol})/(1.07 \text{ mL} \times 2) = 0.0205 \text{ M}.$ 0.0205 M.

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⁽¹¹⁾ No detectable change in the concentration of **2** was observed by 1H NMR over the course (124 min) of one current kinetic study of the reaction between 1 and 12 equiv of Li(THF)₃SiBu^{*I*}Ph₂ at 233 K.

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Scheme 1. Possible Mechanic Pathways in the Conversion of **1** to **2**

 C_{THF}^n , and eq 6b is thus

$$
k_{\rm obs}' = \frac{k_1 k_2 C_{\rm LiSiBuPh_2}}{k_{-1} C_{\rm LiSi(SiMe_3)_3} + k_2 C_{\rm LiSiBuPh_2}}
$$
(7a)

or

$$
\frac{1}{k_{\text{obs}'}} = \frac{k_{-1}C_{\text{LiSi(SiMe}_3)_3}}{k_1k_2C_{\text{LiSiBuPh}_2}} + \frac{1}{k_1}
$$
(7b)

In other words, a plot of $1/k_{\rm obs}'$ vs $C_{\rm LiSi(SiMe_3)_3}/C_{\rm LiSiBu'Ph_2}$ would be linear, yielding values of k_1 and the ratio k_{-1}/k_2 in the dissociative Path I.

If the reaction proceeds by the *associative* pathway in Path II, a steady-state approach gives eq 8a.

$$
-dC_1/dt = \frac{k_3k_4}{k_{-3} + k_4} C_{\text{THF}}^{n} C_{\text{LiSiBuPh}_2} C_1
$$
 (8a)

When the forward reaction for **B** is faster than its reverse reaction (i.e., $k_4 \gg k_{-3}$) and Li(THF)₃SiBu^{*(Ph₂* is in much
excess k_1 , " is a function of C_{trans} (parts b and c of} excess, k_{obs} ["] is a function of $C_{\text{LiSiBu'Ph}_2}$ (parts b and c of eq 8)

$$
-dC_1/dt = k_3 C_{\text{THF}}^n C_{\text{LisibuPh}_2} C_1 = k_{\text{obs}}^{\prime\prime} C_1 \qquad (8b)
$$

$$
k_{\text{obs}}^{\prime\prime} = k_3 C_{\text{THF}}^{\prime\prime} C_{\text{LiSiBuPh}_2} \tag{8c}
$$

The substitution with excess Li(THF)₃SiBu^tPh₂ in mixed THF-toluene- d_8 was completed in a few minutes at room temperature. Current kinetic studies were thus performed at 233 K. Even at 233 K, the reaction was found to be fast, and the fine control of both temperature and time of mixing 1 with Li(THF)₃SiBu^{*(Ph₂* is important to obtaining accurate} kinetic data. In addition, C_{THF} needs to be controlled, as it was found to affect the rate. The kinetics of this silyl substitution was monitored by the disappearance of 1 in H NMR spectra.⁷ Under these conditions, the disappearance of **1** was found to follow the kinetic law in eq 7. A plot of

Figure 1. Kinetic plot of the $1 \rightarrow 2$ conversion.

Table 1. Observed Rate Constants for the $1 \rightarrow 2$ Conversion

$C_{\rm{THF}}$ (M)	$k_{\rm obs} \times 10^4$ (s^{-1})	$k_{\rm obs}$ ' $\times 10^4$ (s^{-1})	$C_{\text{LiSiBu'Ph}(0)}$ (M)	$C_{\text{LiSi(SiMe}_3)}(av)$ C_{LiSiBuPh_2} (av)^{12}
0.67	2.7	5.4	0.101	0.23
0.68	2.7	5.3	0.101	0.23
0.72	3.3	5.6	0.121	0.19
0.72	3.4	5.9	0.121	0.19
0.72	3.7	6.5	0.162	0.14
0.74	3.9	6.6	0.162	0.14
0.67	3.5	6.9	0.202	0.11
0.70	3.8	6.9	0.202	0.11
0.67	3.6	7.1	0.243	0.089
0.61	3.2	7.5	0.243	0.089

Table 2. Rate Constants *k* with Different C_{THF} Values^{*a*}

a The total uncertainty of $\delta k/k = 10\%$ was calculated from $\delta k_{\text{tran}}/k =$ 9.1% and $\delta k_{\text{(sys)}}/k = 5\%$; $C_{1(0)}$ at 0.141 M.

 k_{obs}' vs $C_{\text{Lisi(SiMe}_3)}(av)/C_{\text{Lisibu}'Ph_2}(av)$ (Figure 1) is linear, as expected for the dissociative Path I.

THF Dependence of the $1 \rightarrow 2$ **Conversion.** Both silyl reagents Li(THF)₃Si(SiMe₃)₃ and Li(THF)₃SiBu^rPh₂ contain THF. Li(THF)3Si(SiMe3)3 was also used to prepare **1** in situ*,* which was then employed in the kinetic studies. The presence of THF is thus inevitable in the reactions. In studies to establish the order (*n*) of the reaction with respect to THF, six THF concentrations were used, giving the kinetic plots in Figure 2 and k_{obs} in Table 2. The plot of ln ($k_{obs} \times 10^4$) vs C_{THF} (eq 9) gives a slope (*n*) of 1.7(0.3) (Figure 3).

$$
\ln k_{\text{obs}} = n \ln C_{\text{THF}} + \ln k_1 \tag{9}
$$

As a polar solvent, THF perhaps helps the dissociation of the anionic $Si(SiMe₃)₃$ ⁻ ligand in **1** to give the cationic intermediate $[Ta(NMe₂)₃Si(SiMe₃)₃]⁺ A (Scheme 1). In the$ transition state leading to the formation of cationic **A** (from neutral **1**), there is a significant degree of charge separation. THF may lower the energy of the transition state and the activation energy of the Ta-Si bond cleavage process to give

Figure 2. Kinetic plots of the $1 \rightarrow 2$ conversion with different C_{THF} values.

Figure 3. Plots of $(k_{obs} \times 10^4)$ vs (ln C_{THF}) with different C_{THF} values.

A. A highly solvent-dependent alkylation was reported by DePue and Collum with a seventh order on THF.13 We have also reported that, in $a - SIMe_3^+$ migration process (Scheme
2) the reaction rate is increased by added THE. The reaction 2), the reaction rate is increased by added THF. The reaction is 3.4(0.6)th order with respect to C_{THF} , and this is attributed to a possible multishell of THF molecules around $Li⁺$ cations at the transition state.10

Mechanistic Considerations. As noted earlier, the silyl exchange equilibrium involving *monosilyl* complexes (Me₂N)₃-ZrSi(SiMe₃)₃ and (Me₂N)₃ZrSiBu^{*r*}Ph₂ in eq 1 is likely an associative process through a pentacoordinated, bis(silyl) intermediate {(Me2N)3Zr(SiBu*^t* Ph2)[Si(SiMe3)3]}- (Scheme 3).^{6a} [(Me₂N)₃Zr(SiBu^{*r*}Ph₂)₂]⁻, an analogue of this intermediate, was directly observed in the exchange involving tetracoordinated $(Me_2N)_3Zr-SiBu'Ph_2$ and $SiBu'Ph_2$ ⁻ (eq 2).^{6a} In
the exchange in Scheme 3. (Me₂N).7rSiBu^{*I*ph₂ is thermo-} the exchange in Scheme 3, $(Me_2N)_3ZrSiBu'Ph_2$ is thermodynamically favored over $(Me_2N)_3Zr-Si(SiMe_3)_3$ with, e.g., K_{eq} = 193(1) at 263(1) K (eq 1). The $-Si(SiMe₃)₃$ ligand is bulkier than the $-SiBu'Ph₂$ ligand, although this alone may
not be the deciding factor. The high stability of complexes not be the deciding factor. The high stability of complexes containing the $-SiBu'Ph₂$ ligand(s) may also explain why
 $[(Me₂N)₂Tr(SiRu'Ph₂)]⁻ was observed (and structurally)$ [(Me₂N)₃Zr(SiBu^{*r*}Ph₂)₂]⁻ was observed (and structurally characterized) but not its bis(silyl) analogues containing either one or two $-Si(SiMe₃)₃$ ligands. The observations that complexes containing the $-SiBu'Ph_2$ silyl ligand are more
stable than their $-Si(SiMe_2)$ analogues may also explain stable than their $-Si(SiMe₃)₃$ analogues may also explain

Scheme 3. Silyl Exchanges Involving $(Me_2N)_3ZrSi(SiMe_3)_3$ and (Me2N)3ZrSiBu*^t* Ph2 6a

Scheme 4

why the substitution of the $-Si(SiMe₃)₃$ ligands in **1** and **2** by SiBuPh_2 ⁻ is irreversible (eqs 3-4).

Given the bulky structure of the pentacoordinated, Zr bis- (silyl) complex $[(Me₂N)₃Zr(SiBu[']Ph₂)₂]$ ⁻ (eq 2),^{6a} it is perhaps not surprising that its Ta bis(silyl) analogue $(Me₂N)₃$ - $Ta[Si(SiMe₃)₃]$ ₂ (1) undergoes a dissociative pathway in the substitution by SiBu^{*I*}Ph₂⁻ (Scheme 1, Path I). The first step in this dissociative pathway is similar to the dissociation of one silyl group from the Zr intermediates $[(Me₂N)₃Zr (SiBu'Ph₂)(SiR₃)$ ⁻ $(R₃ = (SiMe₃)₃$, $(Bu'Ph₂)$ in Scheme 3
and ag 2, except that this stap vialds the cationic intermediate and eq 2, except that this step yields the cationic intermediate **A**. **A** reacts with anionic $SiBu'Ph₂⁻$ to give 2.

We reported earlier^{6b} that a mixture of chelating silyl complex K(18-crown-6)_{3/2}{(Me₂N)₃Hf[$η$ ²-(Me₃Si)₂Si(CH₂)₂-Si(SiMe₃)₂]} and excess Li(THF)₃SiBu^{*r*ph₂ revealed no} exchange at 23 °C in 24 h (Scheme 4). This is perhaps not surprising, as the substitution of the chelating ligand by SiBu^{*I*}Ph₂⁻ is thermodynamically unfavorable.

The current studies focus on the substitution reaction between 1 and Li(THF)₃SiBu^{*(Ph*2}. Although limited in scope, the work reveals that the first substitution likely follows a dissociative pathway. A polar solvent was found to promote the substitution. Given the similarities between the first andthe second substitution, the latter, converting **2** to **3**, perhaps also follows a dissociative pathway.

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Supporting Information Available: ¹H NMR spectra of the reaction mixture. This material is available free of charge via the Internet at http://pubs.acs.org.

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